Se	arch	Note:	S

Application/Control No.	Applicant(s)/Patent und Reexamination	der
10/632,039	LIN ET AL.	
Examiner	Art Unit	
Kevin C. Joyner	1744	

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1486			
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INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner
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SEARCH NOT (INCLUDING SEARCH		)
	DATE	EXMR
(clean or sterilize or disinfect) and (vapor near liquid) and @ad<19971217 and rinse near "hydrogen peroxide"	9/6/2006	ксл
Inventor name Search- Lin, Szu Min or Jacobs, Paul Taylor	9/6/2006	ксл
Backward citation search on U.S. Patent No. 6203756	9/6/2006	КСЛ